## AMENDMENTS TO THE CLAIMS

Please cancel claims 43, 45, 49 and 51, and amend claims 42, 47, 48, 50, 52 and 54-58, as follows:

Claims 1-41 (Cancelled).

Claim 42 (Currently Amended) A method for producing a glass sheet coated with [[a]] an anatase-form titanium oxide thin film, which wherein said method comprises:

applying a titanium element-containing liquid comprising anatase-form titanium oxide particles and peroxytitanic acid to the a surface of a glass substrate, wherein the glass substrate is at a temperature of 150°C or lower, has having a surface compressive stress of at most 10 MPa at a temperature of 150°C or lower and comprises from 5 wt. % to 15 wt. % of an alkali metal;[[,]] then

heating the liquid coated surface coated with the liquid up to a maximum temperature of from 600°C to 700°C;[[,]]

maintaining the surface at a temperature of from 550°C to 700°C for a period of from 20 seconds to 500 seconds; and

cooling [[it]] the surface to a temperature of 200°C or lower by applying an air jet to both surfaces of the glass substrate under the condition satisfying the following formula (1) (I) to thereby make the glass substrate have a surface compressive stress of from 20 MPa to 250 MPa:

$$0.2 \le a/t^2 \le 5 \tag{1}$$

wherein a represents the time (second) taken in cooling the surface from 500°C to 200°C, and t represents the thickness of the glass substrate (mm).

Claim 43 (Cancelled).

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Claim 44 (Previously Presented) The method for producing a glass sheet as claimed in

claim 42, wherein the surface is heated under the condition satisfying the following formula (2):

$$5 \le b/t \le 30 \tag{2}$$

wherein b represents the time (second) taken in heating the surface from 200°C to 500°C, t represents the thickness of the glass substrate (mm)

Claim 45 (Cancelled).

Claim 46 (Previously Presented) The method for producing a glass sheet as claimed in

claim 42, wherein the area of the glass substrate is at least 0.5 m<sup>2</sup>.

Claim 47 (Currently Amended) The method for producing a glass sheet as claimed in claim

42, wherein after the surface of the glass substrate is washed the method further comprises, prior to

said applying, washing the surface of the glass substrate with an acidic aqueous solution and a

surfactant-containing aqueous solution, it is coated with the liquid.

Claim 48 (Currently Amended) The method for producing a glass sheet as claimed in claim

42, wherein the titanium element content of the liquid is from 0.1 wt. % to 10 wt. % by weight.

Claim 49 (Cancelled).

Claim 50 (Currently Amended) The method for producing a glass sheet as claimed in claim

42, wherein the mean thickness of the anatase-form titanium oxide thin film to be formed is has a

mean thickness of from 0.02 μm to 1 μm.

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Claim 51 (Cancelled).

Claim 52 (Currently Amended) The method for producing a glass sheet as claimed in claim

42, wherein the a surface of the anatase-form titanium oxide thin film has a ten-point mean

roughness Rz, as defined by JIS B, of the surface of the titanium oxide thin film to be formed is

from 5 nm to 50 nm.

Claim 53 (Previously Presented) The method for producing a glass sheet as claimed in

claim 42, wherein the glass sheet has a haze value of at most 5 %.

Claim 54 (Currently Amended) The method for producing a glass sheet as claimed in claim

42, wherein the titanium element containing liquid is applied to the surface of [[a]] the glass

substrate at a temperature of from 25°C to 100°C.

Claim 55 (Currently Amended) The method for producing a glass sheet as claimed in claim

42, wherein the titanium element-containing liquid is applied to the surface of [[a]] the glass

substrate at a temperature of from 30°C to 80°C.

Claim 56 (Currently Amended) The method for producing a glass sheet as claimed in claim

42, wherein the titanium element-containing liquid is applied to the surface of [[a]] the glass

substrate at a temperature of from 35°C to 60°C.

Claim 57 (Currently Amended) The method for producing a glass sheet as claimed in claim

42, wherein the liquid coated surface coated with the liquid is heated up to a maximum temperature

of from 625°C to 650°C.

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Claim 58 (Currently Amended) The method for producing a glass sheet as claimed in claim 42, wherein the liquid-coated surface is cooled to a temperature of from 200°C to above room temperature.

Claim 59 (Previously Presented) The method for producing a glass sheet as claimed in claim 42, wherein the glass substrate has a surface compressive stress of from 50 MPa to 200 MPa.